



INTERNATIONAL  
GEMOLOGICAL  
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

February 18, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

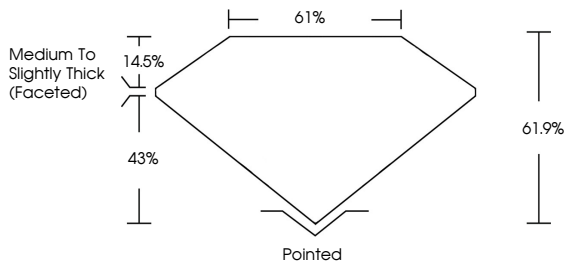
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG774689760

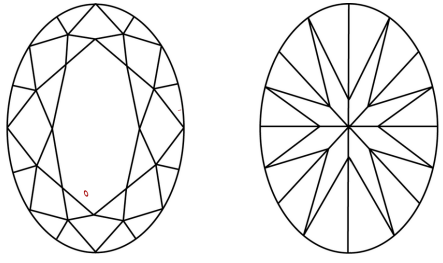
Report verification at [igi.org](#)

PROPORTIONS



Medium To Slightly Thick (Faceted)

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.  
Green symbols indicate external characteristics.

Sample Image Used



COLOR

FL D E F G H I J Faint Very Light Light

CLARITY

FL IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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IGI



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IGI Report No LG774689760

OVAL BRILLIANT

8.79 X 6.46 X 4.00 MM

1.47 CARAT

E

VS 1

61.9%

61%

Medium to Slightly Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG774689760

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